

L Number	Hits	Search Text	DB	Time stamp
1	59	((mask\$4 same writ\$4) and layer and layer and context) and print\$4) and wafer) and (716/\$.ccls. or 430/\$.ccls.) and lithography	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/09/07 06:49
2	8441	lithography near5 mask	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/09/07 07:46
3	864	(lithography near5 mask) and context	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/09/07 07:46
4	321	((lithography near5 mask) and context) and writ\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/09/07 07:46
5	286	((lithography near5 mask) and context) and writ\$3) and layer	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/09/07 07:46
10	1571	(mask\$4 same writ\$4) and layer and layer and context	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/09/07 07:47
11	827	((mask\$4 same writ\$4) and layer and layer and context) and print\$4	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/09/07 07:47
12	322	((mask\$4 same writ\$4) and layer and layer and context) and print\$4) and wafer	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/09/07 07:47
6	25	((lithography near5 mask) and context) and writ\$3) and layer) and 716/\$.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/09/07 07:47
7	89	((lithography near5 mask) and context) and 716/\$.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/09/07 07:47
8	189	(mask\$4 same writ\$4) and layer and 716/\$.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/09/07 07:47
9	2	((lithography near5 mask) and context) and writ\$3) and layer) and interfeature	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/09/07 07:47
13	78	((mask\$4 same writ\$4) and layer and layer and context) and print\$4) and wafer) and (716/\$.ccls. or 430/\$.ccls.)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/09/07 07:47